

Project:

Self-Cleaning and continuous protection of porous building surfaces such as cement, stones, walls and grout

Product:

SurfaShield C

Key Benefits:

- Self Cleaning
- Self Sterilizing
- Superhydrophilic
- Decomposes Odours
- Air purifier
- Continuous Action
- Environmentally friendly cleaning technology

Applications:

- Self-Cleaning of Walls
- Protection from mould growth and organic stains
- Stone and Monument Protection
- Environmental Restoration
- Prevents pollutants adhesion
- Decomposes Pollutants
- Bacterial Growth Inhibition
- Exhaust Gas Break-Down

Packaging:

1L, 4L, 10L, 30L Containers, 1000L IBCs

www.NanoPhos.com



SurfaShield® C

Photocatalytic Self-Cleaning Nanotechnology for the Protection of Porous Surfaces

SurfaShield C decomposes organic stains and pollutants, prevents microbial growth, purifies the air, removes odours. It is an active nanotechnology formulation that can be easily applied on exterior porous surfaces, such as cement, render or plaster, mortar grout, walls, stones or even unpolished marble. By harnessing the surrounding light, treated surfaces become Self Cleaning and Self Sterilizing. SurfaShield coated surfaces efficiently decompose organic stains, bacteria, mould, gaseous pollutants, even odours. SurfaShield C modified surfaces are safer, without the need to use hazardous disinfectants or chemicals, and are preserved as new.



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SurfaShield® is a registered trademark of NanoPhos SA
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